

DOCKET NO: 264681US0X PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :
KAI SCHUMACHER, ET AL. : EXAMINER: LIAO, DIANA J.
SERIAL NO: 10/524,037 :
FILED: FEBRUARY 9, 2005 : GROUP ART UNIT: 1793
FOR: SILICON DIOXIDE DISPERSION :

AMENDMENT AFTER FINAL REJECTION

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Final Rejection dated May 5, 2009, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 5 of this paper.